

<b>Notice of References Cited</b>	Application/Control No. 10/770,245	Applicant(s)/Patent Under Reexamination YANG ET AL.	
	Examiner David S. Blum	Art Unit 2813	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,479,348 B1	11-2002	Kamal et al.	438/258
	B	US-5,418,176 A	05-1995	Yang et al.	438/262
	C	US-6,037,227 A	03-2000	Hong, Gary	438/276
	D	US-6,653,191 B1	11-2003	Yang et al.	438/258
	E	US-6,653,190 B1	11-2003	Yang et al.	438/258
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Stanley Wolf SILICON PROCESSING FOR THE VSLI ERA Vol. 1 1986 Lattice Press pages 298-299
	V	Dielectric Materials, Google search, permittivity, 5/25/05
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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